# e2v

# CCD42-40 NIMO Back Illuminated High Performance CCD Sensor

# **FEATURES**

- 2048 by 2048 pixel format
- 13.5 mm square pixels
- Image area 27.6 x 27.6 mm
- Back Illuminated format for high quantum efficiency
- Full-frame operation
- Symmetrical anti-static gate protection
- Very low noise output amplifiers
- Dual responsivity output amplifiers
- Wide dynamic range for 15-bit operation
- Gated dump drain on output register
- 100% active area
- New compact footprint package

# APPLICATIONS

- Scientific Imaging
- Microscopy
- Medical Imaging

# INTRODUCTION

This version of the CCD42 family of CCD sensors has fullframe architecture. Back illumination technology, in combination with extremely low noise amplifiers, makes the device well suited to the most demanding applications requiring a high dynamic range. To improve the sensitivity further, the CCD is manufactured without anti-blooming structures. The CCD is available with either standard or deep depleted silicon.

There are two low noise amplifiers in the read out register, one at each end. Charge can be made to transfer through either or both amplifiers by making the appropriate  $R \ensuremath{\varnothing}$  connections. The readout register has a gate controlled dump drain to allow fast dumping of unwanted data.

The register is designed to accommodate four image pixels of charge and a summing well is provided capable of holding six image pixels of charge. The output amplifier has a feature to enable the responsivity to be reduced, allowing the reading of such large charge packets.

Other variants of the CCD42-40 available are front illuminated format and inverted mode. In common with all e2v technologies CCD Sensors, the front illuminated CCD42-40 can be supplied with a fibre-optic window or taper, or with a phosphor coating.

Designers are advised to consult e2v should they be considering using CCD sensors in abnormal environments or if they require customised packaging.



# **TYPICAL PERFORMANCE**

#### (Low noise mode)

| Maximum readout frequency     | 3     | MHz                    |
|-------------------------------|-------|------------------------|
| Output amplifier responsivity | 4.5   | 5 μV/e⁻                |
| Peak signal                   | 150   | ke <sup>-</sup> /pixel |
| Dynamic range (at 20 kHz)     | ≘     | ≝50,000:1              |
| Spectral range                | 200 – | 1060 nm                |
| Readout noise (at 20 kHz)     | 3     | e⁻ rms                 |

# **GENERAL DATA**

#### Format

| Image area27                        | .6 x 27.6 mm   |
|-------------------------------------|----------------|
| Active pixels (H)                   |                |
|                                     |                |
| Pixel size                          | 13.5 x 13.5 mm |
| Number of output amplifiers         | 2              |
| Number of underscan (serial) pixels |                |
| Fill factor                         | 100%           |

#### Package

| Package size                    |                   |
|---------------------------------|-------------------|
| Number of pins                  |                   |
| Inter-pin spacing               | 2.54mm            |
| Inter-row spacing across sensor | 45.72 mm          |
| Window material                 | removable glass   |
| Package type                    | ceramic DIL array |

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# PERFORMANCE

|  | Min                          | Typical                                 | Max                       |   |
|--|------------------------------|---|---------------------------|---|
| Peak charge storage (see note 1)   | 100k                         | 150k                                    | -                         | e <sup>-</sup> /pixel   |
| Peak output voltage (unbinned)   | -                            | 675                                     | -                         | mV  |
| Dark signal at 293 K (see notes 2 and 3)   | -                            | 20,000                                  | 45,000                    | e <sup>-</sup> /pixel/s   |
| Dynamic range (see note 4)   | -                            | 50,000:1                                | -                         |   |
| Charge transfer efficiency (see note 5):<br>parallel<br>serial<br>Output amplifier responsivity:<br>low noise mode (see note 3)<br>high signal mode<br>Readout noise at 243 K:<br>low noise mode (see notes 3 and 6) | 99.999<br>99.999<br>3.0<br>- | 99.9999<br>99.9993<br>4.5<br>1.5<br>3.0 | -<br>-<br>6.0<br>-<br>4.0 | %<br>%<br>μV/e <sup>-</sup><br>μV/e <sup>-</sup><br>rms e <sup>-</sup> /pixel |
| high signal mode   | -                            | 6.0                                     | -                         | rms e⁻/pixel  |
| Maximum readout frequency (see note 7)   | -                            | 20                                      | 3000                      | kHz   |
| Dark signal non-uniformity at 293 K<br>(std. deviation) (see notes 3 and 8)  | -                            | 2000                                    | 4500                      | e⁻/pixel/s  |
| Output node capacity (see note 9)  | -                            | 1,000,000                               | -                         | e <sup>-</sup>  |

# SPECTRAL RESPONSE AT 243 K

## **Standard Silicon**

|                    |                                  | Minimum R                                  | esponse (QE) (s  | ee note 10) |                            | Maximum |   |
|--------------------|----------------------------------|--|--|-------------|----------------------------|---------|---|
| Wavelength<br>(nm) | Enhanced<br>Process<br>UV Coated | Enhanced<br>Process<br>Broadband<br>Coated | ced Basic Basic Response<br>ess Process Process Process Non-uniformity<br>and Mid-band Broadband Uncoated (1g) |             | Response<br>Non-uniformity |         |   |
| 300                | 45                               | -  | -  | -           | -                          | -       | % |
| 350                | 45                               | 50   | 15   | 25          | 10                         | 5       | % |
| 400                | 55                               | 80   | 40   | 55          | 25                         | 3       | % |
| 500                | 60                               | 80   | 85   | 75          | 55                         | 3       | % |
| 650                | 60                               | 75   | 85   | 75          | 50                         | 3       | % |
| 900                | 30                               | 30   | 30   | 30          | 30                         | 5       | % |

## **Deep Depleted Silicon**

| Wayalanath         | Minimum Re                            | esponse (QE)                             | Maximum Response                 |   |
|--------------------|---------------------------------------|--|----------------------------------|---|
| Wavelength<br>(nm) | Astronomy Process<br>Broadband Coated | Basic Process NIR<br>(ER1 900 nm) Coated | Non-uniformity (1 <sub>o</sub> ) |   |
| 300                | -                                     | -  | -                                | % |
| 350                | 40                                    | -  | 5                                | % |
| 400                | 70                                    | 25                                       | -                                | % |
| 500                | 75                                    | 45                                       | -                                | % |
| 650                | 70                                    | 75                                       | 3                                | % |
| 900                | 40                                    | 45                                       | 5                                | % |
| 1000               | -                                     | -  | -                                | % |

# ELECTRICAL INTERFACE CHARACTERISTICS

# Electrode Capacitances (Measured at mid-clock level)

|  | Min | Typical | Мах |    |
|--|-----|---------|-----|----|
| IØ/IØ interphase                                 | -   | 16      | -   | nF |
| IØ/SS  | -   | 32      | -   | nF |
| RØ/RØ interphase                                 | -   | 80      | -   | pF |
| RØ/(SS + DG + OD)                                | -   | 150     | -   | pF |
| Output impedance at typical operating conditions | -   | 350     | -   | Ω  |

# NOTES

- 1. Signal level at which resolution begins to degrade.
- Measured between 243 and 293 K typically. The typical average (background) dark signal at any temperature T (kelvin) between 230 K and 300 K may be estimated from:

$$Q_d/Q_{d0} = 122T^3 e^{-6400/T}$$

where Q d0 is the dark signal at 293 K.

- 3. Test carried out at e2v technologies on all sensors.
- 4. Dynamic range is the ratio of full-well capacity to readout noise measured at 243 K and 20 kHz readout frequency.
- 5. CCD characterisation measurements made using charge generated by X-ray photons of known energy.
- 6. Measured using a dual-slope integrator technique (i.e. correlated double sampling) with a 20  $\mu s$  integration period.
- 7. Readout above 3 MHz can be achieved but performance to the parameters given cannot be guaranteed.
- 8. Measured between 243 and 293 K, excluding white defects.
- 9. With output circuit configured in low responsivity/high capacity mode (OG2 high).
- 10. The uncoated process is suitable for soft X-ray and EUV applications.

# **BLEMISH SPECIFICATION**

- TrapsPixels where charge is temporarily held.<br/>Traps are counted if they have a<br/>capacity greater than 200 e<sup>-</sup> at 243 K.Slipped columnsAre counted if they have an amplitude<br/>greater than 200 e<sup>-</sup>.Black costsAre counted when they have a cignal
- Black spots Are counted when they have a signal level of less than 80% of the local mean at a signal level of approximately half full-well.
- White spots Are counted when they have a generation rate 25 times the specified maximum dark signal generation rate (measured between 243 and 293 K). The typical temperature dependence of white spot blemishes is the same as that of the average dark signal i.e.:

$$Q_d/Q_{d0} = 122T^3e^{-6400/T}$$

**Column defects** A column which contains at least 50 white or 50 black defects.

#### Standard Silicon

| GRADE                             | 0   | 1   | 2   |
|-----------------------------------|-----|-----|-----|
| Column defects;<br>black or white | 0   | 3   | 6   |
| Black spots                       | 100 | 150 | 250 |
| Traps >200 e <sup>−</sup>         | 10  | 20  | 30  |
| White spots                       | 100 | 150 | 200 |

#### Deep Depleted Silicon

Grade 5

| GRADE                             | 0   | 1   | 2    |
|-----------------------------------|-----|-----|------|
| Column defects;<br>black or white | 3   | 6   | 10   |
| Black spots                       | 250 | 500 | 1000 |
| Traps >200 e <sup>-</sup>         | 20  | 30  | 40   |
| White spots                       | 250 | 500 | 800  |

Devices which are fully functional, with image quality below that of grade 2, and which may not meet all other performance parameters.

**Note:** The effect of temperature on defects is that traps will be observed less at higher temperatures but more may appear below 243 K. The amplitude of white spots and columns will decrease rapidly with temperature.

# TYPICAL SPECTRAL RESPONSE (At -30 °C, no window)

## **Standard Silicon**





#### **Deep Depleted Silicon**

# TYPICAL OUTPUT CIRCUIT NOISE (Measured using clamp and sample)



**TYPICAL VARIATION OF DARK CURRENT WITH SUBSTRATE VOLTAGE** 



## **TYPICAL VARIATION OF DARK SIGNAL WITH TEMPERATURE**



#### **DEVICE SCHEMATIC**



|     |      |                                  | CLOCK<br>LOW | C           | LOCK HIGH O<br>DC LEVEL (V) | R             | MAXIMUM RATINGS                 |
|-----|------|----------------------------------|--------------|-------------|-----------------------------|---------------|---------------------------------|
| PIN | REF  | DESCRIPTION                      | Typical      | Min         | Typical                     | Max           | with respect to V <sub>ss</sub> |
| 1   | SS   | Substrate (see note 11)          | n/a          | 0           | 0                           | 10            | -                               |
| 2   | OG1  | Output gate 1                    | n/a          | 2           | 3                           | 4             | ±20 V                           |
| 3   | OSL  | Output transistor source (left)  | n/a          |             | see note 12                 |               | –0.3 to +25 V                   |
| 4   | ODL  | Output drain (left)              | n/a          | 27          | 29                          | 31            | –0.3 to +25 V                   |
| 5   | RDL  | Reset drain (left)               | n/a          | 15          | 17                          | 19            | –0.3 to +25 V                   |
| 6   | DD   | Dump drain                       | n/a          | 22          | 24                          | 26            | –0.3 to +25 V                   |
| 7   | DG   | Dump gate (see note 13)          | 0            | -           | 12                          | 15            | ±20 V                           |
| 8   | RDR  | Reset drain (right)              | n/a          | 15          | 17                          | 19            | –0.3 to +25 V                   |
| 9   | ODR  | Output drain (right)             | n/a          | 27          | 29                          | 31            | –0.3 to +25 V                   |
| 10  | OSR  | Output transistor source (right) | n/a          | see note 12 |                             | –0.3 to +25 V |                                 |
| 11  | OG2  | Output gate 2 (see note 14)      | 4            | 16          | 20                          | 24            | ±20 V                           |
| 12  | SS   | Substrate                        | n/a          | 0           | 9                           | 10            | -                               |
| 13  | SS   | Substrate                        | n/a          | 0           | 9                           | 10            | -                               |
| 14  | ØR   | Reset gate                       | 0            | 8           | 12                          | 15            | ±20 V                           |
| 15  | SW   | Summing well                     |              |             | Clock as RØ3                |               | ±20 V                           |
| 16  | IØ3  | Image area clock, phase 3        | 0            | 8           | 10                          | 15            | ±20 V                           |
| 17  | IØ1  | Image area clock, phase 1        | 0            | 8           | 10                          | 15            | ±20 V                           |
| 18  | IØ2  | Image area clock, phase 2        | 0            | 8           | 10                          | 15            | ±20 V                           |
| 19  | RØ2L | Register clock phase 2 (left)    | 1            | 8           | 11                          | 15            | ±20 V                           |
| 20  | RØ1L | Register clock phase 1 (left)    | 1            | 8           | 11                          | 15            | ±20 V                           |
| 21  | RØ3  | Register clock phase 3           | 1            | 8           | 11                          | 15            | ±20 V                           |
| 22  | RØ1R | Register clock phase 1 (right)   | 1            | 8           | 11                          | 15            | ±20 V                           |
| 23  | RØ2R | Register clock phase 2 (right)   | 1            | 8           | 11                          | 15            | ±20 V                           |
| 24  | SS   | Substrate                        | n/a          | 0           | 9                           | 10            | -                               |

## CONNECTIONS, TYPICAL VOLTAGES AND ABSOLUTE MAXIMUM RATINGS

If all voltages are set to the typical values, operation at or close to specification should be obtained. Some adjustment within the range specified may be required to optimise performance. Refer to the specific device test data if possible.

Maximum voltages between pairs of pins:

## NOTES

- 11. Devices can be operated with a low substrate (0 V) or higher substrate (9 V). Low substrate is particularly recommended for deep depleted variance to ensure best estimate.
- 12. Not critical; OS = 3 to 5 V below OD typically. Connect to ground using a 3 to 5 mA current source or appropriate load resistor (typically 5 to 10 k $\Omega$ ).
- 13. This gate is normally low. It should be pulsed high for charge dump.
- 14. OG2 = OG1 + 1 V for operation of the output in high responsivity, low noise mode. For operation at low responsivity, high signal, OG2 should be set high.
- 15. With the RØ connections shown, the device will operate through both outputs simultaneously. In order to operate from the left output only, RØ1(R) and RØ2(R) should be reversed.

# FRAME READOUT TIMING DIAGRAM



# **DETAIL OF LINE TRANSFER (Not to scale)**



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## DETAIL OF VERTICAL LINE TRANSFER (Single line dump)



**DETAIL OF VERTICAL LINE TRANSFER (Multiple line dump)** 



# DETAIL OF OUTPUT CLOCKING (Operation through both outputs)



# LINE OUTPUT FORMAT (Split read-out operation)



# **CLOCK TIMING REQUIREMENTS**

| Symbol                            | Description   | Min                   | Typical            | Max               |    |
|-----------------------------------|---|-----------------------|--------------------|-------------------|----|
| Ti                                | Image clock period  | 10                    | 20                 | see note 16       | μS |
| t <sub>wi</sub>                   | Image clock pulse width                                   | 5                     | 10                 | see note 16       | μS |
| t <sub>ri</sub>                   | Image clock pulse rise time (10 to 90%)                   | 1                     | 2                  | 0.2T <sub>i</sub> | μS |
| t <sub>fi</sub>                   | Image clock pulse fall time (10 to 90%)                   | t <sub>ri</sub>       | t <sub>ri</sub>    | 0.2T <sub>i</sub> | μS |
| t <sub>oi</sub>                   | Image clock pulse overlap                                 | $(t_{ri} + t_{fi})/2$ | 2                  | 0.2T <sub>i</sub> | μS |
| t <sub>dir</sub>                  | Delay time, IØ stop to RØ start                           | 3                     | 5                  | see note 16       | μS |
| t <sub>dri</sub>                  | Delay time, $R \varnothing$ stop to $I \varnothing$ start | 1                     | 2                  | see note 16       | μS |
| Tr                                | Output register clock cycle period                        | 300                   | see note 17        | see note 16       | ns |
| t <sub>rr</sub>                   | Clock pulse rise time (10 to 90%)                         | 50                    | 0.1T <sub>r</sub>  | 0.3T <sub>r</sub> | ns |
| t <sub>fr</sub>                   | Clock pulse fall time (10 to 90%)                         | t <sub>rr</sub>       | 0.1T <sub>r</sub>  | 0.3T <sub>r</sub> | ns |
| t <sub>or</sub>                   | Clock pulse overlap                                       | 20                    | 0.5t <sub>rr</sub> | 0.1T <sub>r</sub> | ns |
| t <sub>wx</sub>                   | Reset pulse width   | 30                    | 0.1T <sub>r</sub>  | 0.3T <sub>r</sub> | ns |
| t <sub>rx</sub> , t <sub>fx</sub> | Reset pulse rise and fall times                           | 20                    | 0.5t <sub>rr</sub> | 0.1T <sub>r</sub> | ns |
| t <sub>dx</sub>                   | Delay time, ØR low to RØ3 low                             | 30                    | 0.5Tr              | 0.8Tr             | ns |

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## NOTES

16. No maximum other than that necessary to achieve an acceptable dark signal at the longer readout times.

17. As set by the readout period.

# **OUTPUT CIRCUIT**



## NOTES

18. The amplifier has a DC restoration circuit which is internally activated whenever  $I \oslash 3$  is high.

19. External load not critical; can be a 3 to 5 mA constant current supply or an appropriate load resistor.

# OUTLINES (All dimensions in millimetres; dimensions without limits are nominal) Standard Ceramic Package



#### Metal Base Package (available to special order)



## **ORDERING INFORMATION**

Options include:

- Temporary quartz window
- Temporary glass window
- Fibre-optic coupling
- UV coating
- X-ray phosphor coating

For further information on the performance of these and other options, contact e2v.

## HANDLING CCD SENSORS

CCD sensors, in common with most high performance MOS IC devices, are static sensitive. In certain cases a discharge of static electricity may destroy or irreversibly degrade the device. Accordingly, full antistatic handling precautions should be taken whenever using a CCD sensor or module. These include:

- Working at a fully grounded workbench
- Operator wearing a grounded wrist strap
- All receiving socket pins to be positively grounded
- Unattended CCDs should not be left out of their conducting foam or socket.

Evidence of incorrect handling will invalidate the warranty. All devices are provided with internal protection circuits to the gate electrodes (pins 2, 7, 11, 14, 15, 16, 17, 18, 19, 20, 21, 22, 23) but not to the other pins.

## **HIGH ENERGY RADIATION**

Device parameters may begin to change if subject to an ionising dose of greater than  $10^4$  rads.

Certain characterisation data are held at e2v technologies. Users planning to use CCDs in a high radiation environment are advised to contact e2v.

## **TEMPERATURE LIMITS**

|           | Min | Typical | Max |   |
|-----------|-----|---------|-----|---|
| Storage   | 153 | -       | 373 | Κ |
| Operating | 153 | 243     | 323 | Κ |

Operation or storage in humid conditions may give rise to ice on the sensor surface on cooling, causing irreversible damage.

Maximum device heating/cooling ......5 K/min